Facile hydrothermal synthesis of crystalline Ta₂O₅ nanorods, MTaO₃ (M=H, Na, K, Rb) nanoparticles, and their photocatalytic behaviour.

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Supporting Information

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Fig. S1. Left: Photograph of the product obtained by an upscaled reaction. Right: Reaction TEM image of a snapshot after 12 h for pH = 4.



Fig. S2. Histogramm of the NTaO₃ nanorods synthesized at pH=12 (left) and pH=13 (right).



Fig. S3. TEM micrograph of the Ta_2O_5 nanorods synthesized with 5 mM NaOH.



Fig. S4. Histograms of the KTaO₃ (left) and RbTaO₃ (right) nanoparticles synthesized at pH=12.



Fig. S5. EDX of the rods with 5 mM RbOH.



Fig. S6. X-ray diffraction patterns of the tantalum oxide rods with 5 mM NaOH, KOH and RbOH respectively. Reflection profiles look wider than those in Fig. 2 as these were recorded on diffractometers with different instrumental broadening.



Fig. S7. UV-VIS spectra of the samples after stirring in the dark for 18 minutes and centrifugation of the nanoparticles.

Tab. S1. Measurement and refinement parameters of the x-ray diffraction pattern of products prepared at different pH-values

	pH = 3	pH = 4	pH = 7	pH = 8	pH = 9	pH = 12	pH = 13
Diffractometer	Siemens D5000						
Sample preparation	Fine powder fixed between two stripes of Scotch™ tape						
Measuring mode	Transmission						
Wavelength	1.540596						
Measuring range	$10 \le 2\Theta /^{\circ} \le 90;$	$0.71 \le Q / Å^{-1} \le 5.7$	7				
Temperature /K	298K						
Profile Fit	Rietveld refinem	ent according to rep	orted crysta	l structure m	odels		
Background	Chebyshev						
Profile function	Fundamental Par	ameters Approach					
Program	TOPAS Academ	ic V5					
Total No. of Parameters / Background	29 / 20	29 / 20			33 / 20	27 / 20	33 / 20
Rexp	1.97	3.47			2.06	1.96	1.94
R _{wp}	4.21	6.55		1	6.72	5.17	4.97
GoF	2.92	1.89			3.26	2.64	2.52
DW	0.36	0.69			0.25	0.30	0.52
			1				
Ta ₂ O ₅ – oP14							
Space group					Pccm		
Cell parameters /Å	a = 3.6188(5)	a =			a = 3.5810(1)		
	b = 6.304(2)	3.6264(5)			b = 6.14(4)		
	c = 7.7910(1)	b = 6.318(2) c = 7.8097(9)			c = 7.775(2)		
Crystallite size / nm	41(1) (ab)	47(1) (ab)			48(2)		
	70(1) (c)	75(1) (c)					
Fraction /%wt	100	100			15(2)		
Biso	3.3(1)	3.4(1)			3.0 fixed		
Preferred Orientation	1.33(1)/	1.38(1)/			3.3(2) / (020)		
	(020)	(020)					
H ₂ Ta ₂ O ₆ ·H ₂ O – <i>cF</i> 104							
Space group			1	1	Fd-3m		I
Cell parameter /Å					a = 10.457(2)	a = 10.5249(3)	a = 10.5237(5)
Crystallite size / nm	1			1	33(1)	47(1)	21(1)
Eraction /%wt				1	85(1)	100	83(1)
Biso					3 (fixed)	3 (fixed)	3 (fixed)
site occupation factor 16d				1	1 00(6)	0.42(1)	0.39(2)
Site occupation factor 8b					1.00(0)	0.37(3)	0.28(4)
approx composition				1	Na _a Ta _a O _a ·H _a O	Na	Nac TacOci0 28HcO
NaTaO $= oP10$					1102102061120	1140.84111.1614206 0.011120	1140.7811.2214206 0.201120
Space group							Pnma
Cell parameter /Å				-			2 = 5.5258(3)
							h = 7.7971(4)
							c = 5.4839(3)
Crystallite size / nm					1		> 100nm
Fraction //wt					1		17(2)
Biso							3.0 (fixed)
2.00							

Tab. S2. Measurement and refinement parameters of the x-ray diffraction pattern of the cube-shaped nanoparticles with different bases.

Rb h ^{тм} tape	K Siemens D5000	Na				
h™ tape	Siemens D5000					
h™ tape	1 6 11		Diffractometer			
	wder fixed between two stripes of Scote	Fine powder fixed between two stripes of Scotch [™] tape				
	Transmission					
	Wavelength					
	Measuring range					
	Temperature /K					
acture models	Profile Fit					
	Background					
	Profile function					
	Program					
	Total No. of Parameters /					
	Background					
3.59	1.97	1.96	R _{exp}			
7.41	5.57	5.17	R _{wp}			
2.06	2.83	2.64	GoF			
0.49	0.30	0.30	DW			
			H ₂ Ta ₂ O ₆ ·H ₂ O – <i>cF</i> 104			
	Space group					
10.6146(7)	10.6324(2)	10.5249(3)	Cell parameter /Å			
31(1)	68(1)	47(1)	Crystallite size / nm			
100	100	100	Fraction /%wt			
	Biso					
0.098(5)	0.488(8)	0.42(1)	site occupation factor 16d			
1.00(5)	0.00(3)	0.37(3)	Site occupation factor 8b			
Rb _{0.2} H _{1.8} Ta ₂ O ₆ ·1H ₂ O	K _{0.97} H _{1.03} Ta ₂ O ₆	Na _{0.88} H _{1.12} Ta ₂ O ₆ ·0.37H ₂ O	approx. composition			
2.06 0.49 10.6146(7) 31(1) 100 0.098(5) 1.00(5) Rb _{0.2} H _{1.8} Ta ₂ O ₆ ·1H ₂ O	$\begin{array}{c} 1.340390 \\ 10 \leq 200 /^{\circ} \leq 90; \ 0.71 \leq Q/A^{-1} \leq 5.77 \\ 298K \\ \text{nement according to reported crystal str Chebyshev \\ \hline Chebyshev \\ \hline Fundamental Parameters Approach \\ \hline TOPAS Academic V5 \\ 27 / 20 \\ \hline 1.97 \\ 5.57 \\ 2.83 \\ 0.30 \\ \hline \\ \hline \\ Fd-3m \\ \hline 10.6324(2) \\ 68(1) \\ 100 \\ 3 \text{ (fixed) } \\ 0.488(8) \\ 0.00(3) \\ \hline \\ K_{0.97}H_{1.03}Ta_2O_8 \\ \hline \end{array}$	Rietveld refin 1.96 5.17 2.64 0.30 10.5249(3) 47(1) 100 0.42(1) 0.37(3) Nao.seH1.12Ta2O6.0.37H2O	Wavelength Measuring range Temperature /K Profile Fit Background Profile function Program Total No. of Parameters / Background Rexp Rexp GoF DW HzTa2Oe:HzO - cF104 Space group Cell parameter /A Crystallite size / nm Fraction /%wt Biso site occupation factor 16d Site occupation factor 8b approx. composition			

Nononartial	A nolyto/	Calibration	Maggurad	Llaad/lrang	Concentration/	Status
Nanopartici	Analyte/	Calibration	wieasured	Used/kcps	Concentration/	Status
es	Compound	Status	/kcps		%	
	Formula					
NaTaO ₃	Na	Calibrated	6.102	5.587	12.551	Calculate
	Та	Calibrated	77.874	78.487	87.449	Calculate
HCl washed	Al	Calibrated	0.101	0.097	0.187	Calculate
NaTaO ₃	Та	Calibrated	46.512	46.769	99.813	Calculate
KTaO ₃	Al	Calibrated	0.137	0.124	0.102	Calculate
	Si	Calibrated	0.569	0.460	0.481	Calculate
	Κ	Calibrated	7.553	7.554	9.019	Calculate
	Та	Calibrated	100.934	101.813	90.398	Calculate
HCl washed	Si	Calibrated	0.614	0.490	0.540	Calculate
KTaO ₃	S	Calibrated	0.346	0.232	0.101	Calculate
	K	Calibrated	0.483	0.434	0.551	Calculate
	Та	Calibrated	104.688	105.518	98.808	Calculate
RbTaO ₃	Rb	Calibrated	151.266	151.206	27.107	Calculate
	Та	Calibrated	84.145	84.646	72.893	Calculate
HCl washed	Та	Calibrated	84.973	85.650	100.000	Calculate
RbTaO ₃						

Tab. S3. XRF data of the cube-shaped MTaO₃ (M=Na, K, Rb) before and after treatment with 2 M HCl.

Tab. S4. Measurement and refinement parameters of the x-ray diffraction pattern of the acid treated cube-shaped nanoparticles and the heat treated rods and cube shaped nanoparticles

	Pristine	After HCI treatment	750°C	850°C			
Diffractometer		Siemen	s D5000				
Sample preparation	Fine powder fixed between two stripes of Scotch [™] tape						
Measuring mode	Transmission						
Wavelength	1.540596						
Measuring range	$10 \le 2\Theta /^{\circ} \le 90; \ 0.71 \le Q / Å^{-1} \le 5.77$						
Temperature /K		29	8K				
Profile Fit		Rietveld refinement according to	reported crystal structure models				
Background		Chebyshev					
Profile function		Fundamental Par	ameters Approach				
Program		TOPAS Academic V5					
Total No. of Parameters /	27 / 20	27 / 20	25 / 20	25 / 20			
Background							
R _{exp}	1.97	1.98	2.03	2.12			
R _{wp}	5.57	5.37	5.75	10.78			
GoF	2.83	2.72	2.83	5.09			
DW	0.30	0.31	0.33	0.16			
H ₂ Ta ₂ O ₆ ·H ₂ O – <i>cF</i> 104							
Space group	Fo	1-3 <i>m</i>					
Cell parameter /Å	10.6324(2)	10.6014(2)					
Crystallite size / nm	68(1)	71(1)					
Fraction /%wt	100	100					
Biso	3 (fixed)						
site occupation factor 16d	0.488(8)	0.000(7)					
Site occupation factor 8b	0.00(3)	0.45(3)					
approx. composition	K _{0.97} H _{1.03} Ta ₂ O ₆	H ₂ Ta ₂ O ₆ · 0.45H ₂ O					
Ta₂O₅ – <i>oP</i> 14							
Space group			Pccm				
Cell parameters /Å			a = 3.6380(3),	a = 3.6565(4),			
			b = 6.2670(6),	b = 6.2108(8),			
			c = 7.7824(5)	c = 7.7758(8)			
Crystallite size / nm			33(1) (ab)	20(1) (ab)			
			49(1) (C)	5/(1)(C)			
Fraction /%wt			100%	100%			
BISO			3.09(6)	3.64(9)			
Preferred Orientation			1.052(5) / (0 2 0)	1.086(6) / (0 2 0)			